Electronic Supplementary Information

Ab initio study of nickel-catalyzed transformation of amorphous carbon into graphene in rapid thermal processing

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Fig. S1 Formation energies of Ni···Ni, Ni···C, and C···C as a function of interatomic distance computed using the spin-polarized DFT PBE-D2 method with the double numerical basis set plus polarization (DNP) (implemented in DMol³ 7.0), and using the PBE-D3 and GWP methods (implemented in CP2K). The minimum of the formation energy curve corresponds to bond distance (r_b) and bond energy (E_b) between two bonding atoms. Based on the formation energy curves, the interaction strength in Ni-C system can be estimated to follow this general trend, Ni-Ni < Ni-C < C-C, consistent with the cohesive energy trend of Ni < C (see Kittel C. *Introduction to Solid State Physics*; John Wiley & Sons: New York, 1996).



Fig. S2 Initial configurations of (a) Model I *a*-C/Ni₃C and (b) Model VII graphene/*a*-C/Ni₃C. The Ni and C atoms are shown in blue and grey, respectively, and the perfect first graphene layer is also highlighted with purple vdW surface. Both slab models are viewed along the *y* axis to show the vacuum layer.



Fig. S3 Initial (a-f) and final configurations of (a'-f') of Model I *a*-C/Ni₃C, Model II sp^2 -C/Ni₃C, Model VIII *a*-C/NiC, Model IX sp^2 -C/NiC, Model X *a*-C/Ni, and Model XI sp^2 -C/Ni based on stepwise temperature increase from 300 K, 600 K, 900 K, 1200 K, to 1800 K every 15 ps in AIMD simulations. The Ni and C atoms are shown in blue and grey, respectively. The number of C atom or Ni atom in each model is also highlighted in insets. All the slab models are viewed along the surface *y* axis, and the vacuum layer along the *z* axis for each model is cut to highlight reactive solid layers.



Fig. S4 Variations of mean square displacement (MSD) with time for Ni (solid lines) and C (dashed lines) atoms in NiC layer of Model VIII at (a) 300 K, 600 K, and 900 K and (b) 1200 K and 1800 K, and for Ni atoms in Ni layer of Model X at (c) 300 K, 600 K, and 900 K and (d) 1200 K and 1800 K based on the AIMD simulations. The corresponding linear fitting of the MSD-time curves are in violet.

Table S1 Computed self-diffusion coefficients, D (unit: cm²/s), of Ni or C atoms in Ni₃C layer of Model I, NiC layer of Model VIII, and Ni layer of Model X at different temperatures (stepwise increase every 15 ps) through linear fitting of MSD-time curves shown in Fig. 2 of the main text and Fig. S4, respectively, on basis of AIMD simulations.

	900 K	1200 K	1800 K
		Ni ₃ C layer of Model I	
Ni	3.3×10 ⁻⁷	6.4×10 ⁻⁷	3.7×10 ⁻⁶
С	4.8×10 ⁻⁷	1.6×10 ⁻⁶	8.6×10 ⁻⁶
	Ν	iC layer of <mark>Model VIII</mark>	
Ni	8.7×10^{-7}	4.4×10 ⁻⁶	8.4×10 ⁻⁶
С	1.5×10 ⁻⁶	4.5×10 ⁻⁶	7.5×10 ⁻⁶
		Ni layer of <mark>Model X</mark>	
Ni	5.5×10 ⁻⁷	2.0×10 ⁻⁶	9.2×10 ⁻⁶



Fig. S5 Lindemann index (δ) of (a) NiC layer and (b) *a*-C layer in Model VIII and of (c) Ni layer and (d) *a*-C layer in Model X, estimated from the 15-ps AIMD simulations with temperature increase from 300 K, 600 K, 900 K, 1200 K, to 1800 K.